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Attorney Docket No. H1938

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: :
Zoran Krivokapic : Group Art Unit: 2812
Serial No.: 10/601,401 : Examiner: Not yet assigned
Filed: June 23, 2003 :

Title: SEMICONDUCTOR DEVICE AND METHOD OF MANUFACTURE

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

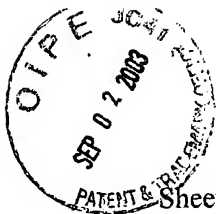
Sir:

Attached hereto is a completed Form PTO-1449 listing patents, publications, or other information which the applicant believes may be material to the examination of this application, with copies of each such item enclosed herewith. It is requested that the cited patents be made of record in the examination of this application. This information disclosure statement is being filed prior to the first Office Action and no certification or fee is required. The Commissioner is authorized to charge any fee deficiency required by this paper or credit any overpayment to Deposit Account No. 50-2173. A duplicate of this communication is enclosed.

Respectfully submitted,

Dated: 29 August 2003

By Rennie William Dover
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Sheet 1 of 1

FORM PTO-1449	U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE	ATTY. DOCKET NO. H1938	SERIAL NO 10/601,401
INFORMATION DISCLOSURE STATEMENT BY APPLICANT (Use several sheets if necessary)		APPLICANT Zoran Krivokapic	
		FILING DATE June 23, 2003	GROUP 2812

U.S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE

FOREIGN PATENT DOCUMENTS

	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
						YES	NO

OTHER DOCUMENTS (Including Author, Title, Date Pertinent Pages, Etc.)

		M.V. Fischetti and S.E. Laux, Band structure, deformation potentials, and carrier mobility in strained Si, Ge, and SiGe alloys, Thomas J. Watson Research Center, J.Appl. Phys. 80(4), 15 August 1996, pp. 2234-2252.

EXAMINER

DATE
CONSIDERED

EXAMINER: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.